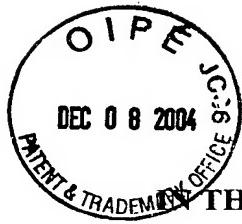


IFW

Attorney Docket No.:
SP02-260



THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor: BELLMAN, ET AL

Serial No: 10/722,769

Filing Date: November 26, 2003

Title: METHOD USING MULTI-COMPONENT COLLOIDAL ABRASIVES FOR CMP PROCESSING OF SEMICONDUCTOR AND OPTICAL MATERIALS

Group Art Unit: 1765

Examiner: CHEN, Kin Chan

RESPONSE

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESPONSE TO THE EXAMINER'S RESTRICTION REQUIREMENT

In response to the Office Action dated November 4, 2004 in the above-captioned application, please enter the following Amendments and Remarks.

No amendment to the specification is being made in this paper.

No amendment to the claims is being made in this paper.

Remarks begin on page 2 in this paper.